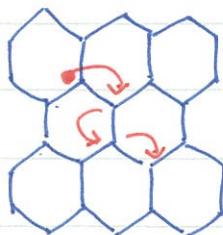


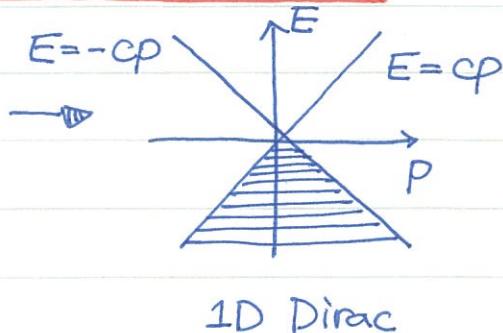
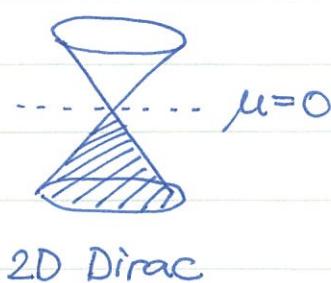
HH0040 Electrons and Holes in Semiconductors

Let us start with the Nobel-Prize-winning material: graphene.



It consists of carbon atoms arranged in 2D honeycomb lattice. Electrons hop (quantum!) on the lattice with relativistic kinetic energy:

$$E(P_x, P_y) = \pm c |\vec{p}| \quad \text{where } |\vec{p}| = \sqrt{p_x^2 + p_y^2}$$



The effective Hamiltonian

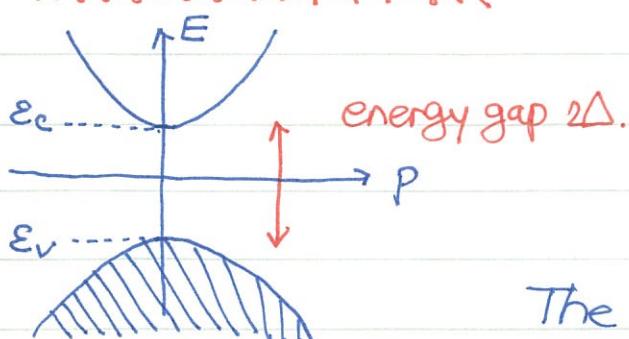
$$H_{\text{eff}}^{(0)} = \begin{pmatrix} cp & 0 \\ 0 & -cp \end{pmatrix}$$

(similar to photons. ⚡)

If the right and left movers are coupled together,

$$H_{\text{eff}} = \begin{pmatrix} cp & \Delta \\ \Delta & -cp \end{pmatrix} \rightarrow E = \pm \sqrt{cp^2 + \Delta^2}$$

relativistic w/
non-zero mass !!.
 $\Delta = m_0 c^2$.



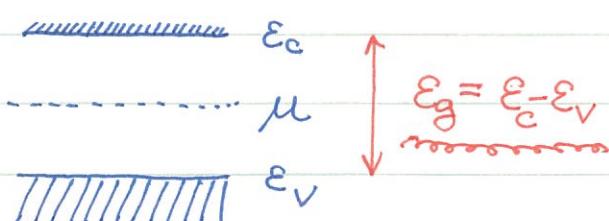
The upper branch (particle) is called conduction band with dispersion

$$\epsilon_c(p) \approx \epsilon_c + \frac{1}{2m_e^*} p^2 + \dots$$

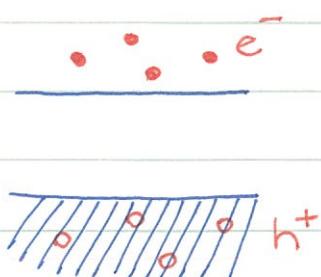
The lower branch (antiparticle) is called valence band with dispersion

$$\epsilon_v(p) \approx \epsilon_v - \frac{1}{2m_h^*} p^2 + \dots$$

Sometimes it is convenient to ignore the p -dependence and plot the band diagram.



The low-energy excitations are electrons + holes



Let's derive an important relation between electron and hole concentrations, often referred as Law of Mass Action $\text{is}^{''}$

$$N_e = \sum_{CB} f_e(\varepsilon) = \sum_{CB} \frac{1}{e^{(\varepsilon-\mu)/\tau} + 1}$$

$$N_h = \sum_{VB} 1 - f_e(\varepsilon) = \sum_{VB} \frac{1}{e^{(\mu-\varepsilon)/\tau} + 1}$$

For holes, it's almost like reverse the signs of μ and ε !

For most semiconductors at room temperature, they are non-degenerate

$$e^{-(\varepsilon-\mu)/\tau} \ll 1 \quad \text{and} \quad e^{-(\mu-\varepsilon)/\tau} \ll 1 \rightarrow \text{in class regime.}$$

The electron number in the conduction band is approximately

$$N_e \approx \sum_{CB} e^{-(\varepsilon-\mu)/\tau} = e^{-(\varepsilon_c-\mu)/\tau} \times \left[\sum_{CB} e^{-(\varepsilon-\varepsilon_c)/\tau} \right]$$

Because $\varepsilon - \varepsilon_c \approx \frac{1}{2m_e^*} P^2$, the sum is the same as the ideal gas discussed before.

$$\sum_{CB} e^{-(\varepsilon-\varepsilon_c)/\tau} = \frac{2N_Q V}{n_c} = \frac{2}{\pi \hbar^2} \left(\frac{m_e^* \tau}{2} \right)^{\frac{3}{2}} V$$

from spin

The electron concentration in the conduction band is

$$n_e = \frac{N_e}{V} = n_c e^{-(\varepsilon_c-\mu)/\tau}$$

$$\mu = \varepsilon_c - \tau \log \left(\frac{n_c}{n_e} \right)$$

similar to the ideal gas

The derivation for hole concentration in valence band follows a similar logic.

$$N_h \approx \sum_{VB} e^{-(\mu-\varepsilon)/\tau} = e^{-(\mu-\varepsilon_v)/\tau} \times \left[\sum_{VB} e^{-(\varepsilon-\varepsilon_v)/\tau} \right] n_v V$$

$$\rightarrow n_h = \frac{N_h}{V} = n_v e^{-(\mu-\varepsilon_v)/\tau} \rightarrow \mu = \varepsilon_v + \tau \log \left(\frac{n_v}{n_h} \right)$$

Combine both results together :

$$n_e n_h = n_c n_v e^{-(\varepsilon_c-\varepsilon_v)/\tau}$$

Note that the band gap is $E_g = E_c - E_v$. The product of electron and hole concentrations is

$$n_e n_h = n_c n_v e^{-E_g/\tau}$$

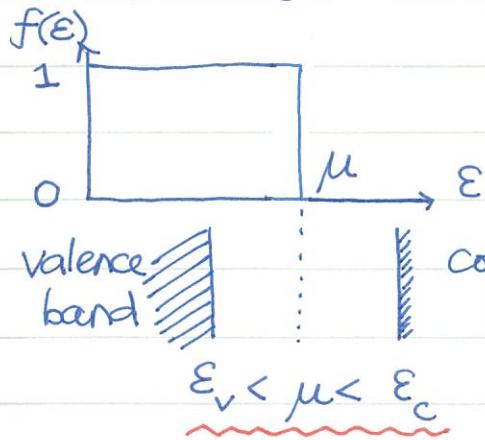
Law of Mass Action.

Compare the relation with electron-positron pair production $e^+ + e^- \rightleftharpoons \text{photons}$.

$$n_e n_{e^-} = n_Q^2 e^{-2m_b c^2/\tau}$$

\uparrow electrons and \uparrow holes in semiconductor are "antiparticles" to each other! CUTE :)

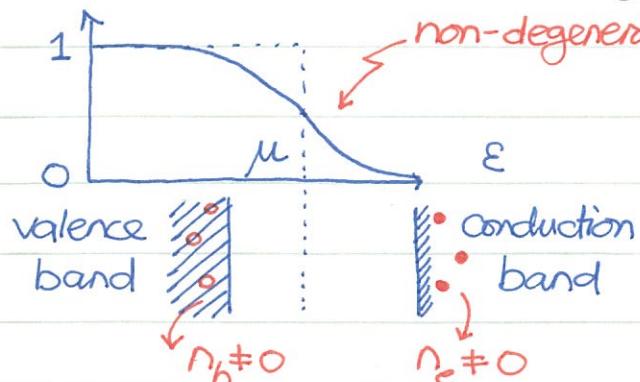
① **Intrinsic Semiconductor:** Suppose the semiconductor is pure without any impurities. What are the concentrations of electrons and holes? For simplicity, take $\tau = 0$ limit first. The electron



gas is degenerate so that the valence band is completely filled (no holes) and the conduction band is completely empty (no electrons).

$$\tau \rightarrow 0 \Rightarrow n_e = 0 \text{ and } n_h = 0$$

However, the situation changes at room temperature, the electron gas is non-degenerate. Let's estimate



non-degenerate the non-vanishing n_e, n_h due to thermal fluctuations.

$$(1) \text{ mass action law: } n_e n_h = n_c n_v e^{-E_g/\tau}$$

$$(2) \text{ charge neutrality: } n_+ = n_-.$$

Since there is no external impurities, $n_+ = n_h$ and $n_- = n_e$

$$\begin{cases} n_e n_h = n_c n_v e^{-E_g/\tau} \\ n_e = n_h \end{cases} \rightarrow \text{intrinsic concentration } n_i = n_e = n_h$$

$$n_i = \sqrt{n_c n_v} e^{-E_g/2\tau}$$

It is also insightful to plot $\log n_e$, $\log n_h$ to find the intrinsic concentration n_i and the chemical potential μ .

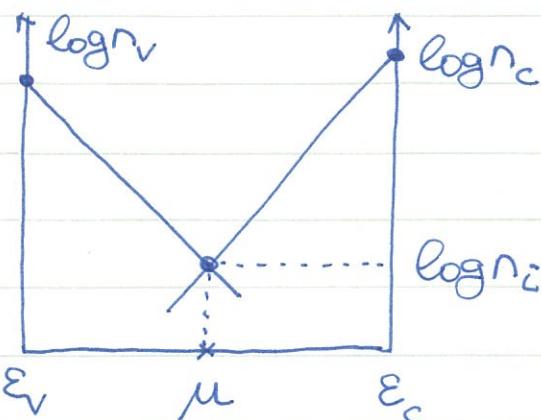
$$n_e = n_c e^{-(\varepsilon_c - \mu)/kT}$$

$$n_h = n_v e^{-(\mu - \varepsilon_v)/kT}$$



$$\log n_e = \log n_c - \frac{1}{kT} (\varepsilon_c - \mu)$$

$$\log n_h = \log n_v - \frac{1}{kT} (\mu - \varepsilon_v)$$



It's rather easy to solve for μ —

$$\log n_e - \log n_h = (\log n_c - \log n_v) + \frac{1}{kT} (2\mu - \varepsilon_c - \varepsilon_v)$$

$$\begin{aligned} \mu &= \frac{1}{2}(\varepsilon_c + \varepsilon_v) + \frac{kT}{2} \log \left(\frac{n_v}{n_c} \right) \\ &= \frac{1}{2}(\varepsilon_c + \varepsilon_v) + \frac{3}{4}kT \log \left(\frac{m_h^*/m_e^*}{m_e^*/m_h^*} \right) \end{aligned}$$

For Si, $\varepsilon_g = 1.14 \text{ eV}$.

$$n_c \approx n_v \approx 10^{19} \text{ cm}^{-3}$$

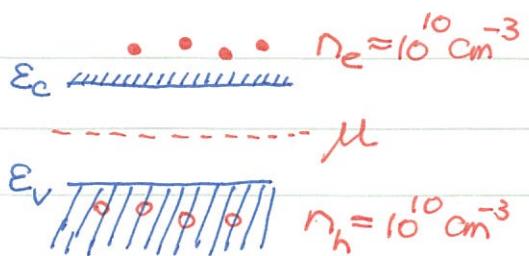
$$m_e^* = 1.06 m_e, m_h^* = 0.58 m_e$$

→ intrinsic concentration $n_i \sim 10^{10} \text{ cm}^{-3}$

Since $m_h^*/m_e^* \sim O(1)$, the chemical potential is $\mu \approx \frac{1}{2}(\varepsilon_v + \varepsilon_c)$

Therefore, at room temperature, the semiconductor without external impurities contains intrinsic concentrations of electrons and holes

$n_e = n_h = n_i$ and the chemical potential is in the middle of the gap.



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